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| <p style="text-align: center;">FORM HDP-1449 (Based on Form PTO-1449)</p> <p style="text-align: center;">PATENT AND TRADEMARK OFFICE INFORMATION DISCLOSURE CITATION (Use several sheets if necessary)</p> <p style="text-align: center;">Sheet 1 of 1</p> | ATTORNEY DOCKET NO. | SERIAL NO. |
| | 1740-000043/US | 10/762,535 |
| | APPLICANT | |
| | Sang Woon SUH et al. | |
| | FILING DATE | GROUP |
| January 23, 2004 | 2627 | |

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| 6 | | Office Action issued December 19, 2008 by the Chinese Patent Office in Chinese Patent Application No. 200480000399.8 (with English language translation) |
| 7 | | Office Action issued November 14, 2008 by the U.S. Patent and Trademark Office in U.S. Patent Application No. 10/762,536 |
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Examiner:

Date Considered:

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